Electronic Acknowledgement Receipt					
EFS ID:	1163923				
Application Number:	10702234				
Confirmation Number:	7943				
Title of Invention:	Reliable high voltage gate dielectric layers using a dual nitridation process				
First Named Inventor:	Rajesh Khamankar				
Customer Number:	23494				
Filer:	Greg H. Parker/Elizabeth Schumacher				
Filer Authorized By:	Greg H. Parker				
Attorney Docket Number:	TI-33223				
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Time Stamp:	15:38:22				
Application Type:	Utility				
International Application Number:					

Payment information:

Submitted with Payment	no
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File Listing:

Document Number	Document Description	File Name	File Size(Bytes)	Multi Part	Pages
1		Amendment.pdf	624430	yes	11

	Multipart Description				
	Doc Desc	Start	End		
	Amendment - After Non-Final Rejection	1	1		
	Specification	2	2		
	Claims	3	5		
	Applicant Arguments/Remarks Made in an Amendment	6	11		
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Warnings:

Information:

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New Applications Under 35 U.S.C. 111

If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.

National Stage of an International Application under 35 U.S.C. 371

If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/DO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filing Receipt, in due course.